

# Re-entrant Negative Coulomb Drag in a 1D Quantum Circuit

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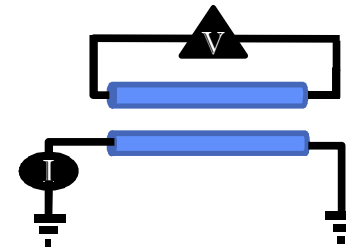
# Motivation

**Goal :** Study electron interactions in 1 dimensional systems

- Address multiple 1D subbands regime
- Electron hole asymmetry
- Luttinger liquid theory

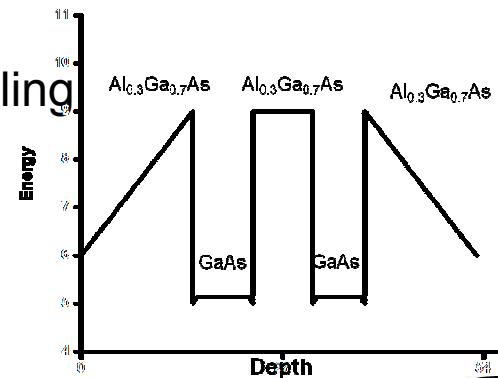
**Tool :** Coulomb Drag measurement

- Direct probe of electron-electron interactions



**How :** Independent and vertically-coupled quantum wires

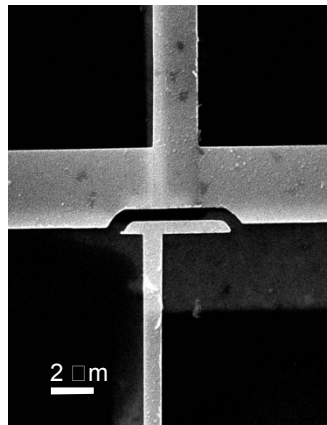
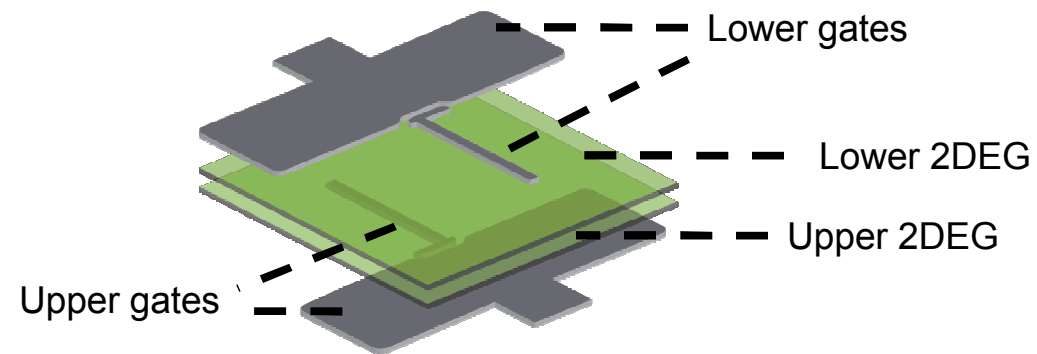
- Direct control of the 1D subband occupancy in each wire independently
- Smaller inter-wire separation without tunnelling
  - Stronger drag signal
  - Stronger coupling between the wires
  - Smaller influence of phonon drag



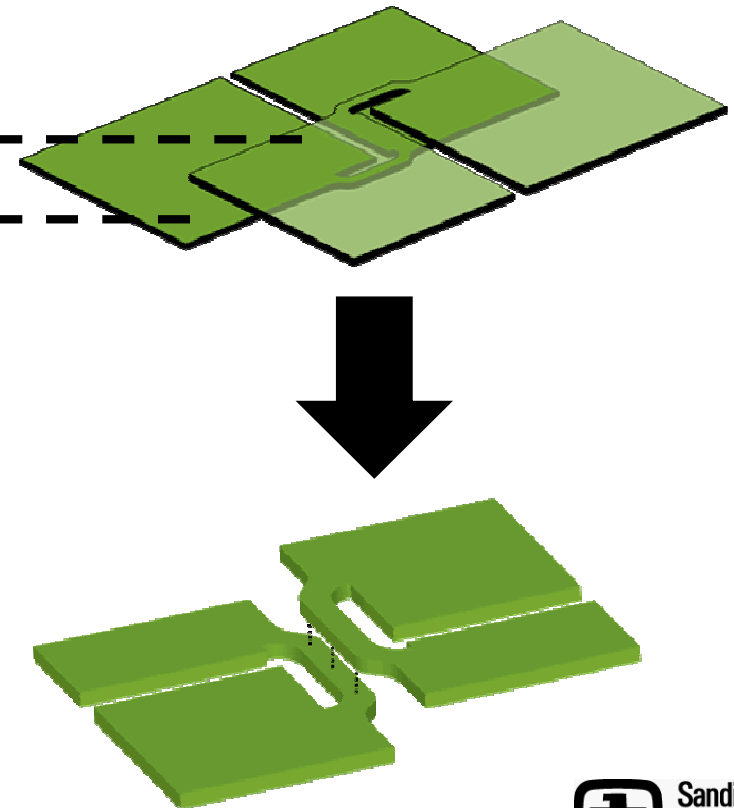
# Sample design and fabrication

- Use 18 nm wide double quantum well heterostructures with a 15 nm barrier.
- Fabricated through an Epoxy-Bound And Stopped-Etch technique\*
- Fabricate 4.2  $\mu\text{m}$  long vertically-coupled quantum wires

## Gates design



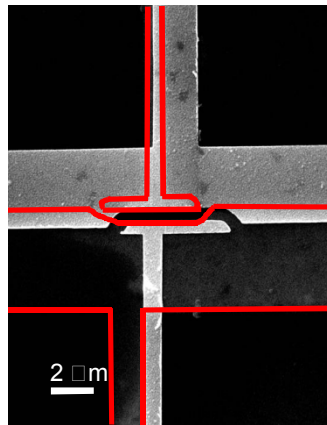
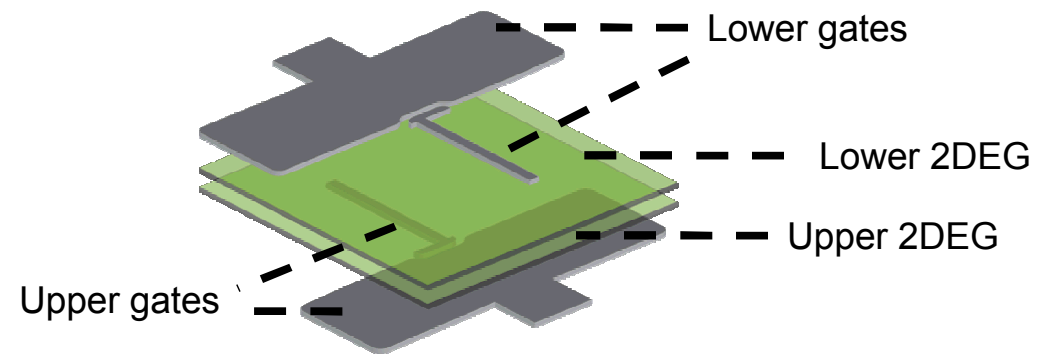
## Gates activated



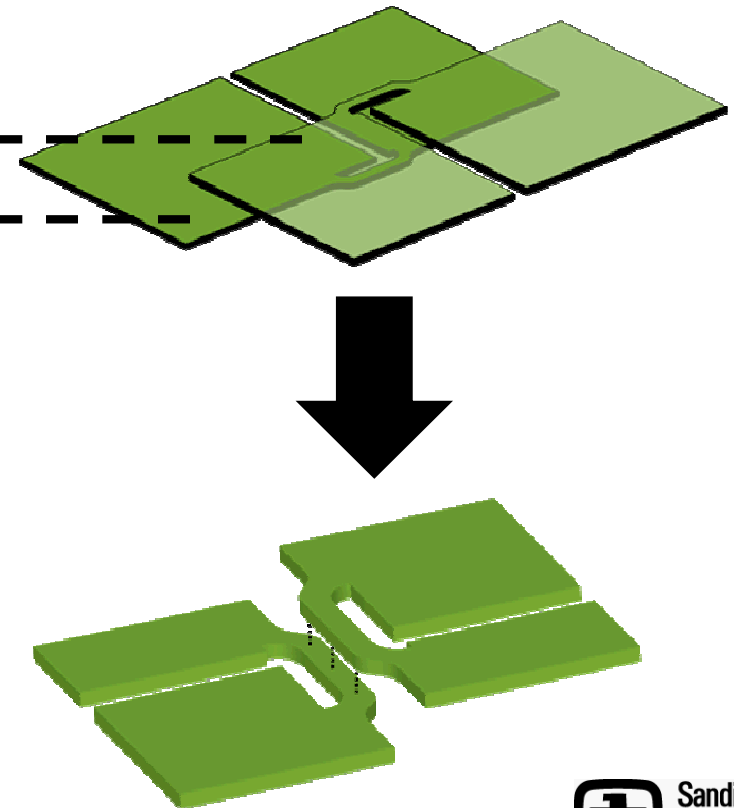
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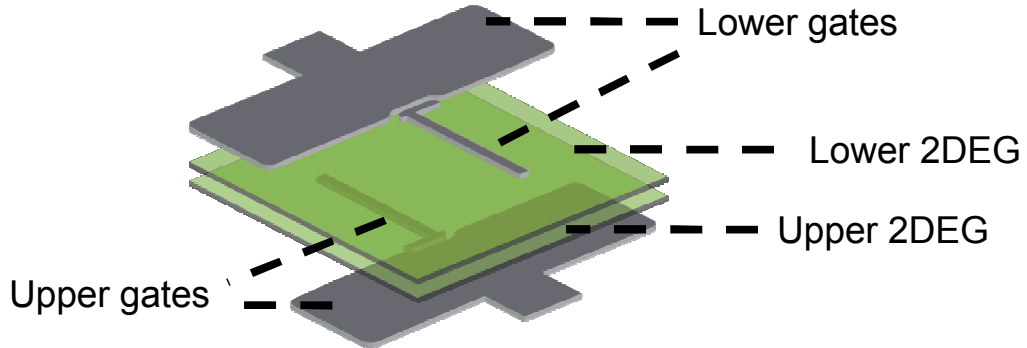
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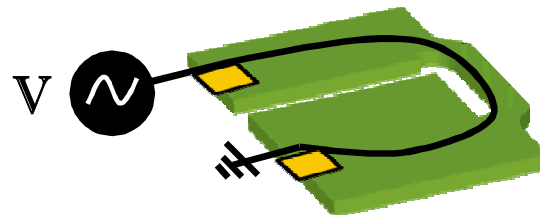
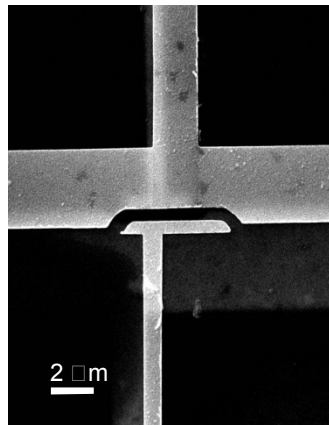
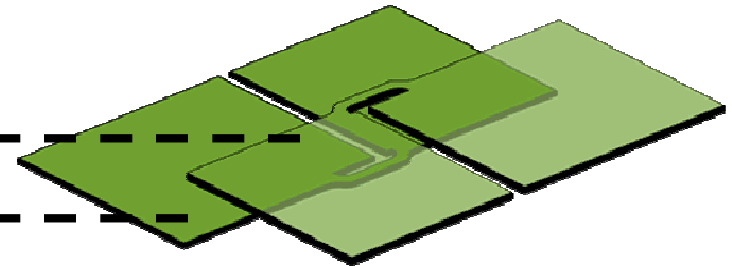
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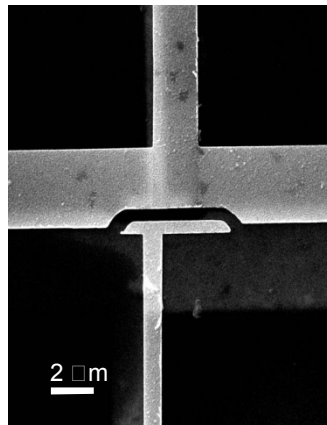
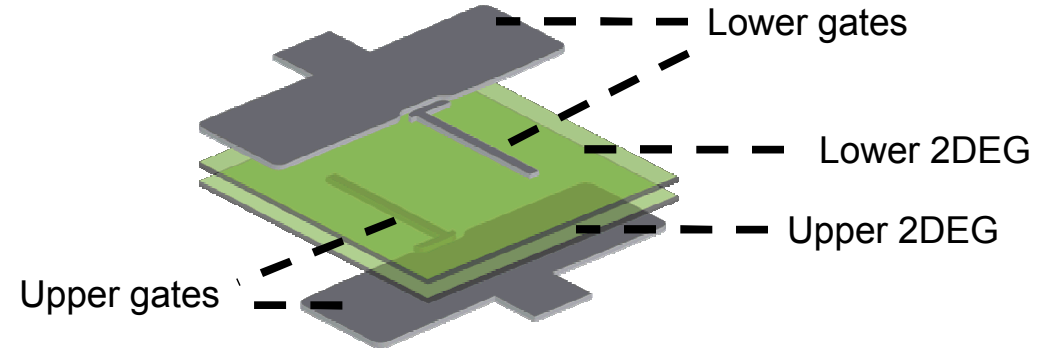
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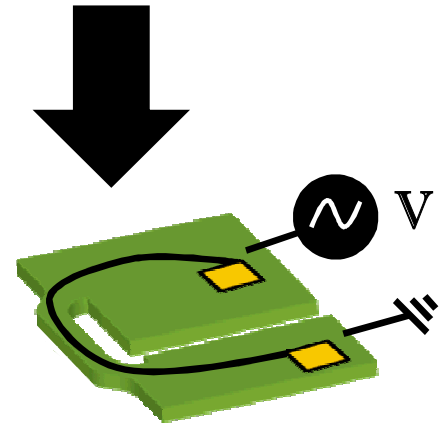
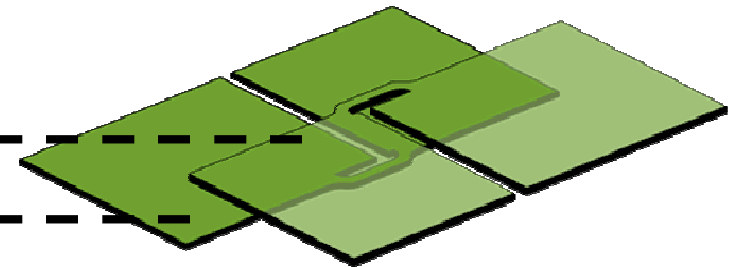
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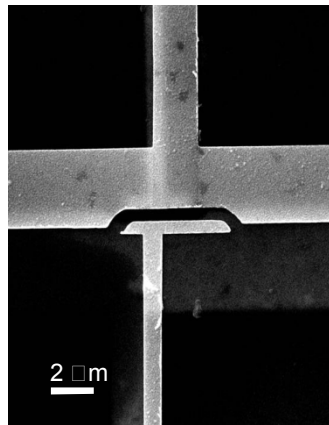
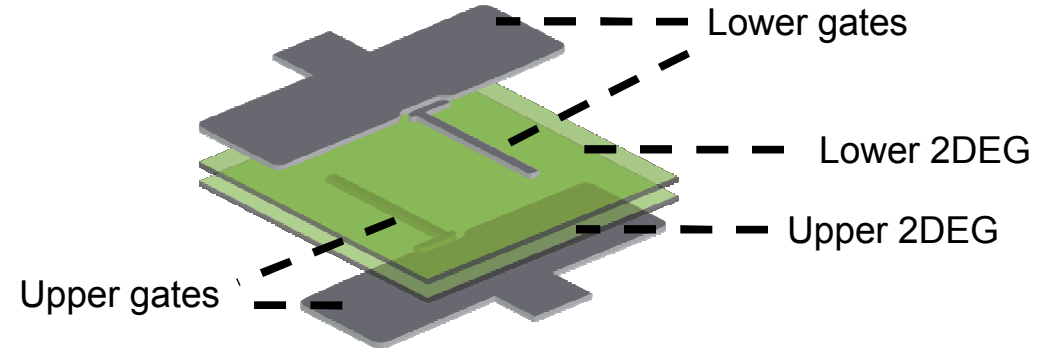
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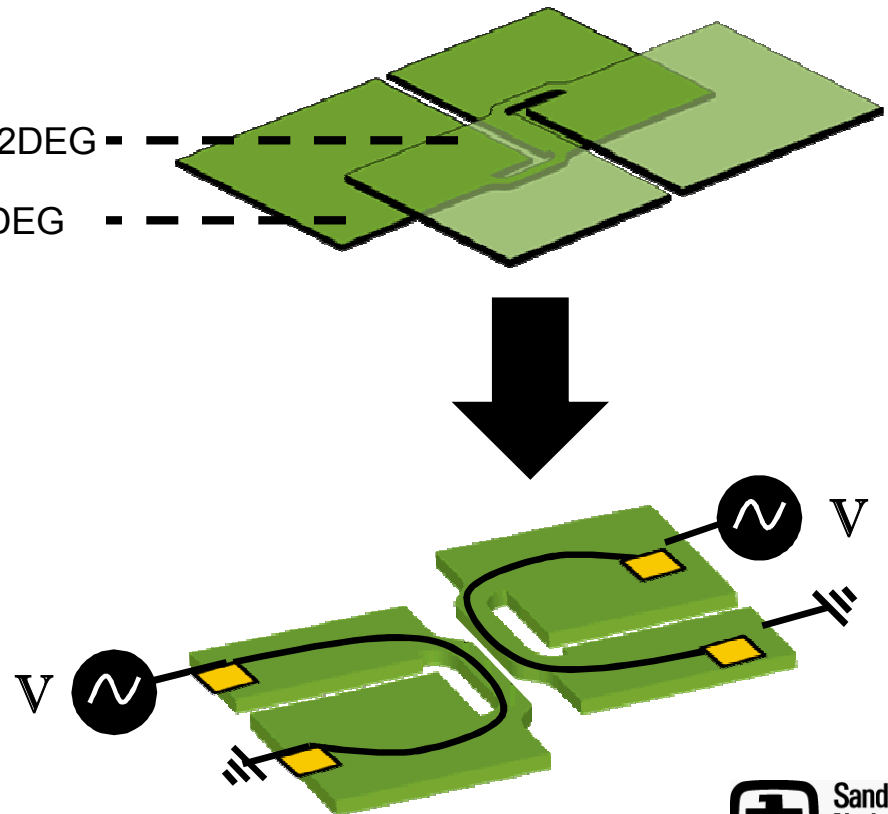
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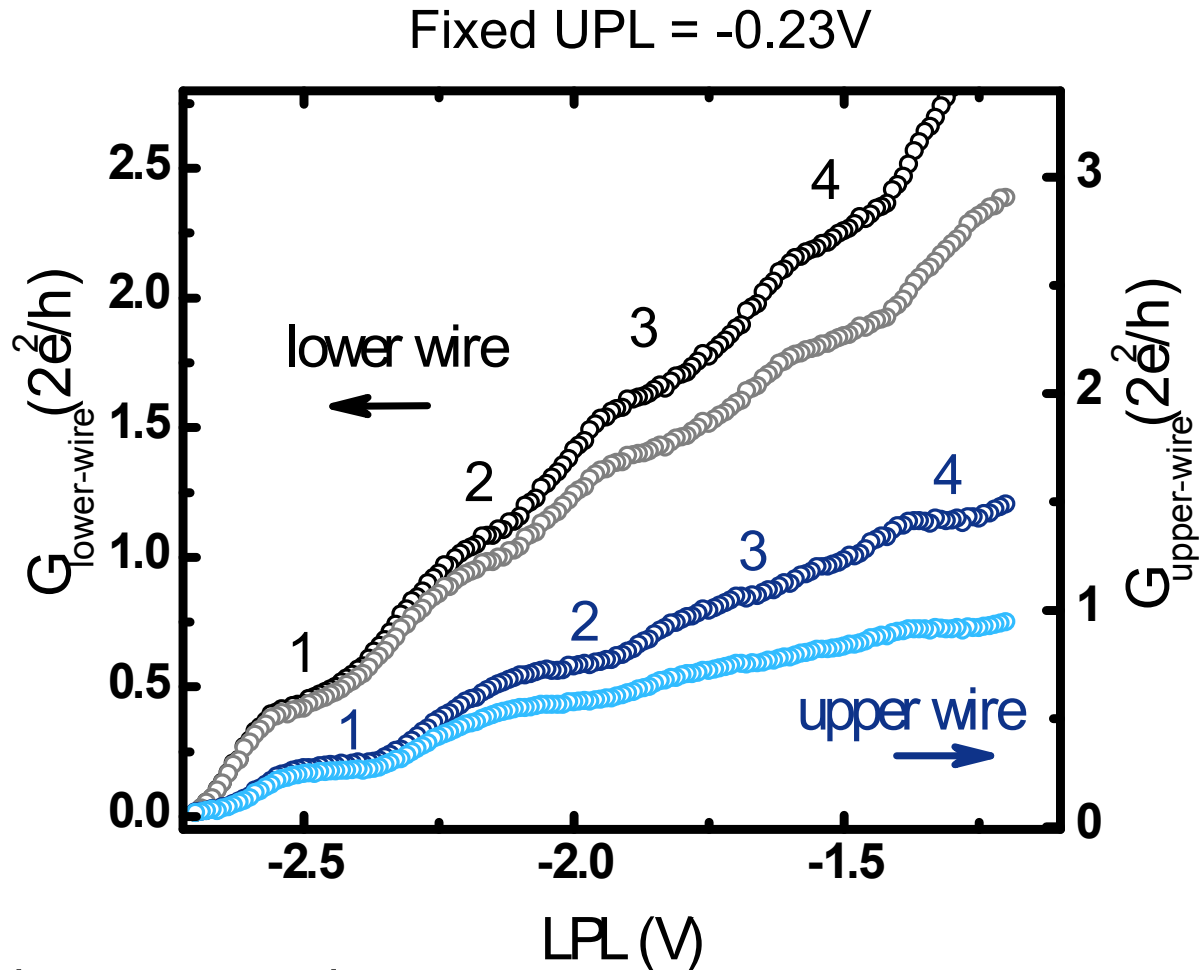
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# Wires characterization

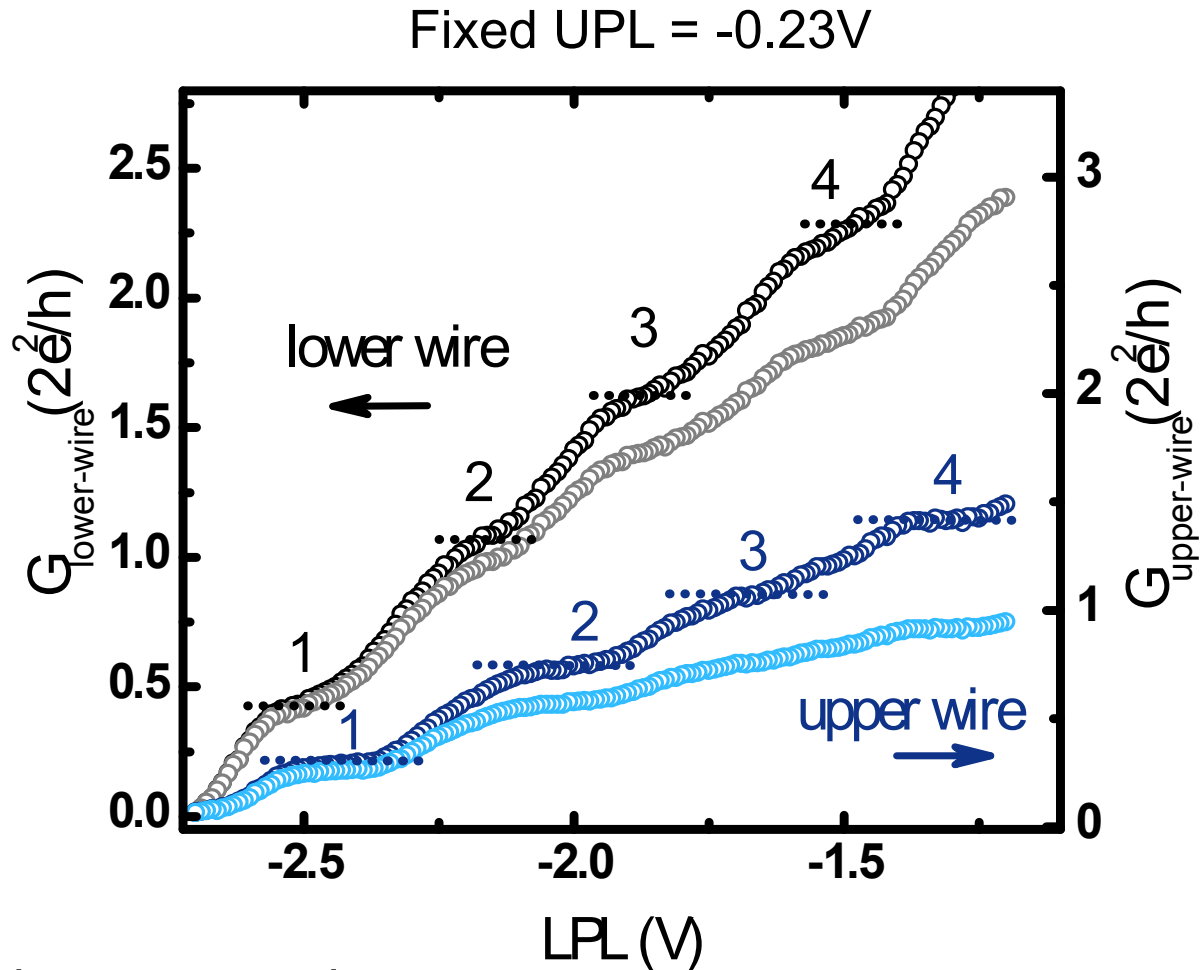


- Non-ballistic quantum wires

➤ After subtracting a series resistance, even plateau-like features spa



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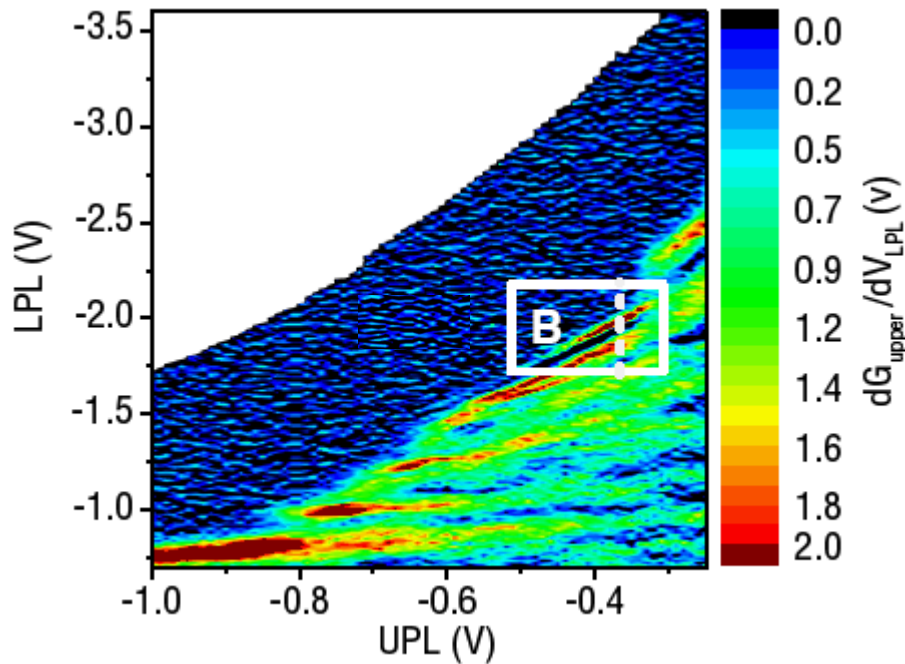
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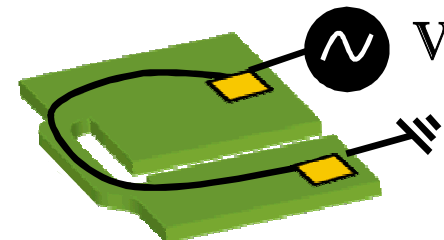
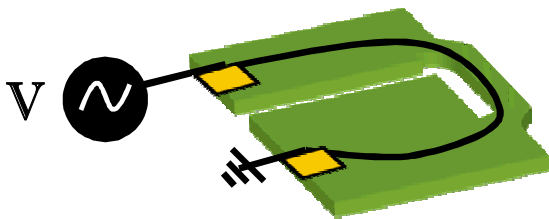
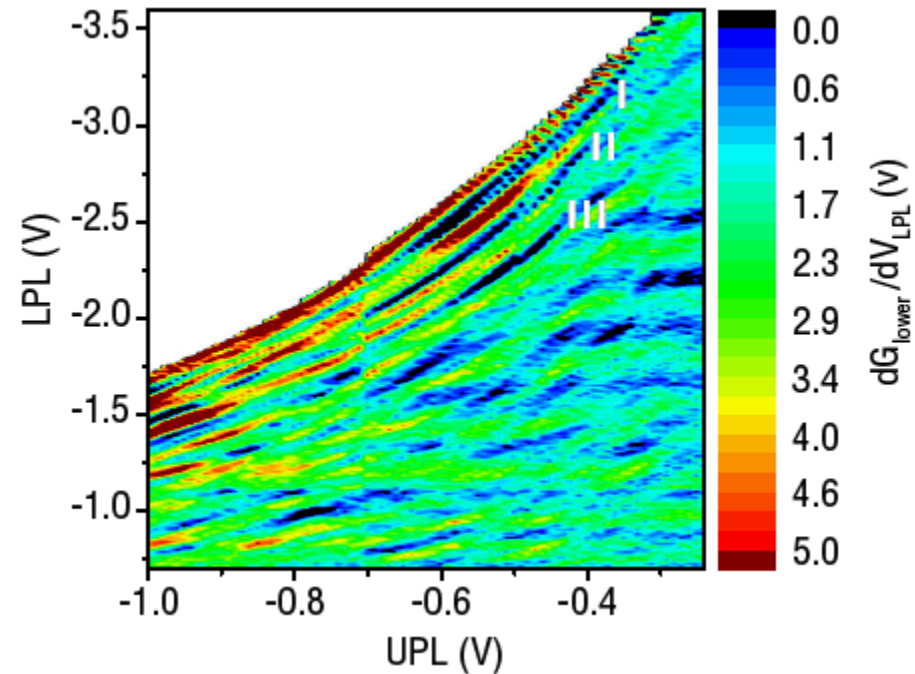
# Wires characterization

Tracking of the 1D subbands over a large range of gates voltage

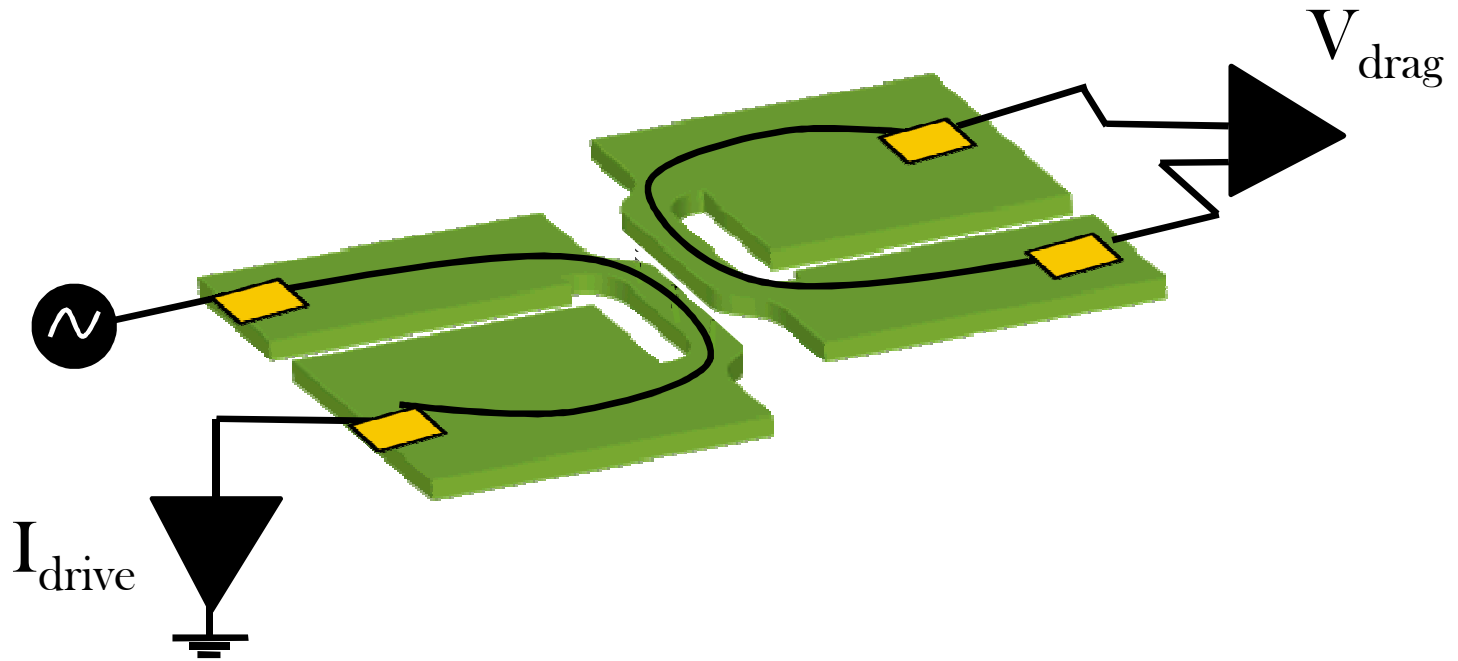
Upper wire derivative



Lower wire derivative



# General Coulomb drag measurements



Measured quantity : transresistance

$$R_D = - \frac{V_{\text{drag}}}{I_{\text{drive}}}$$

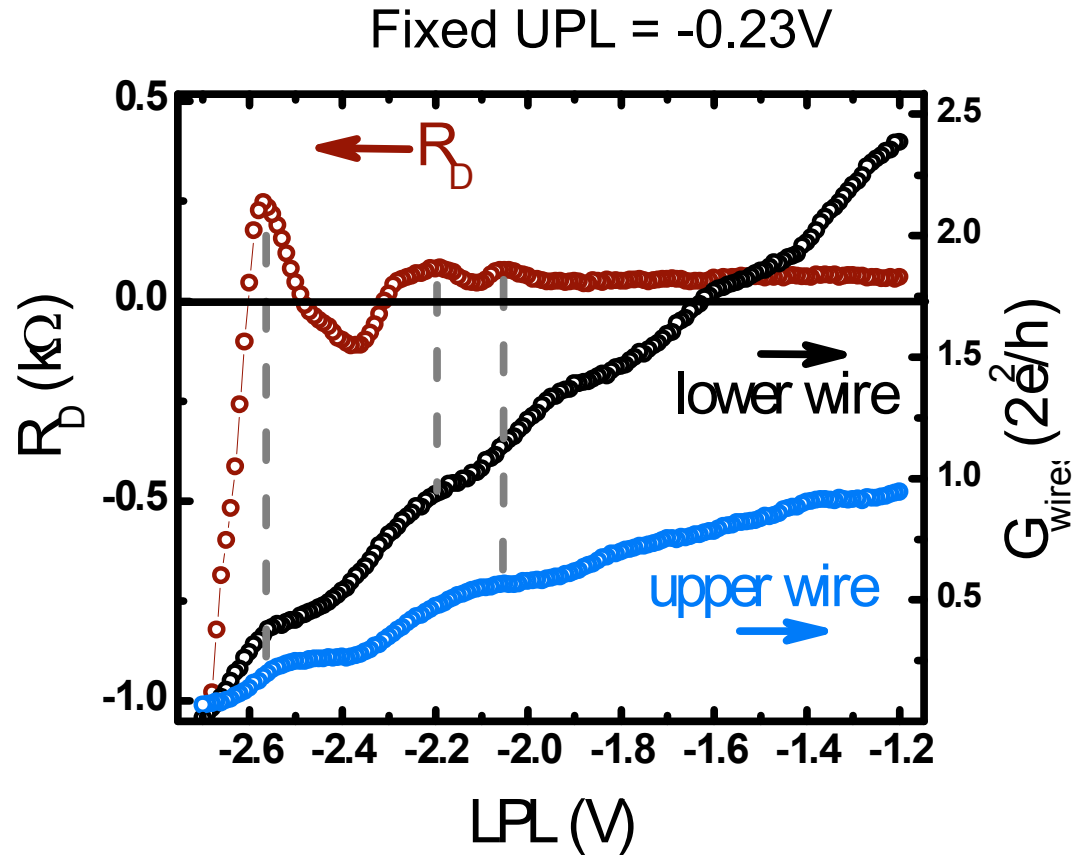
# Coulomb drag results

- Peaks in the drag signal as 1D subbands gets depleted.  
(Previously observed by Debray *et. al.*<sup>1</sup>)
- Low-density negative drag observed when  $N_{\text{wires}} < 1$   
(Previously observed by Yamamoto *et. al.*<sup>2</sup>)
- Re-entrant negative drag at the 1<sup>st</sup> plateau-like feature of the drag wire

➤ Never observed

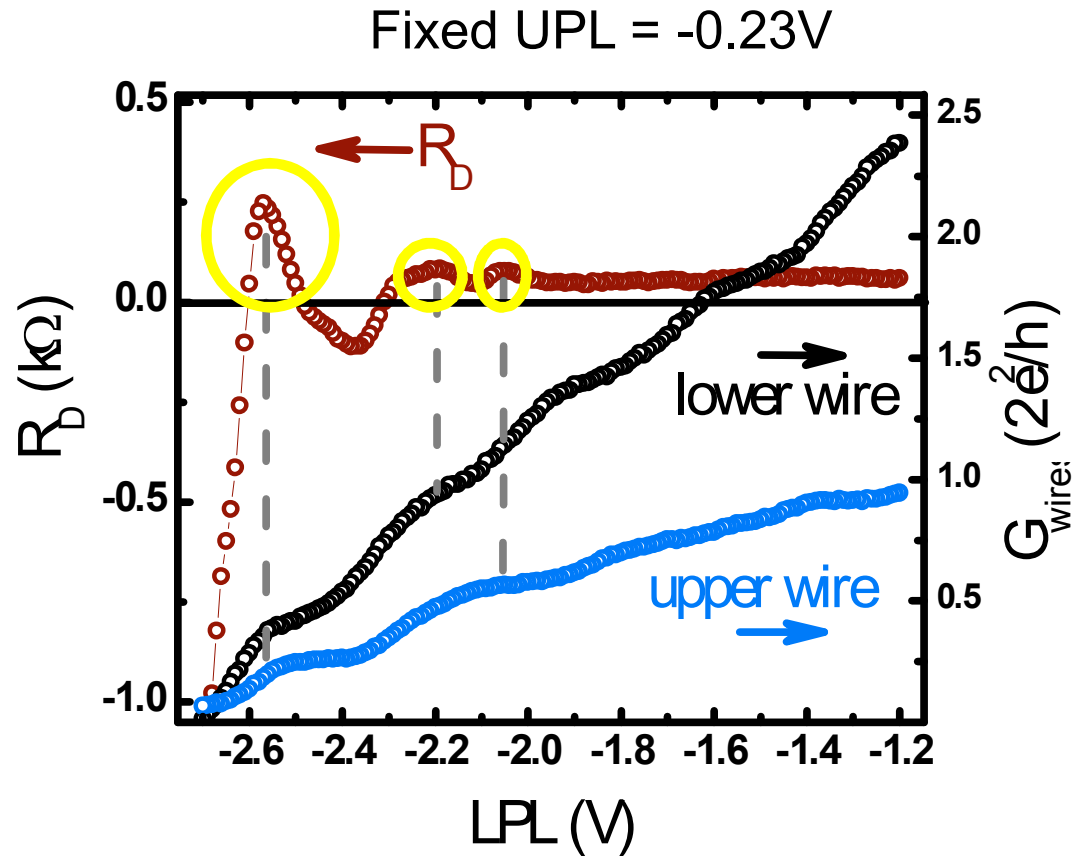
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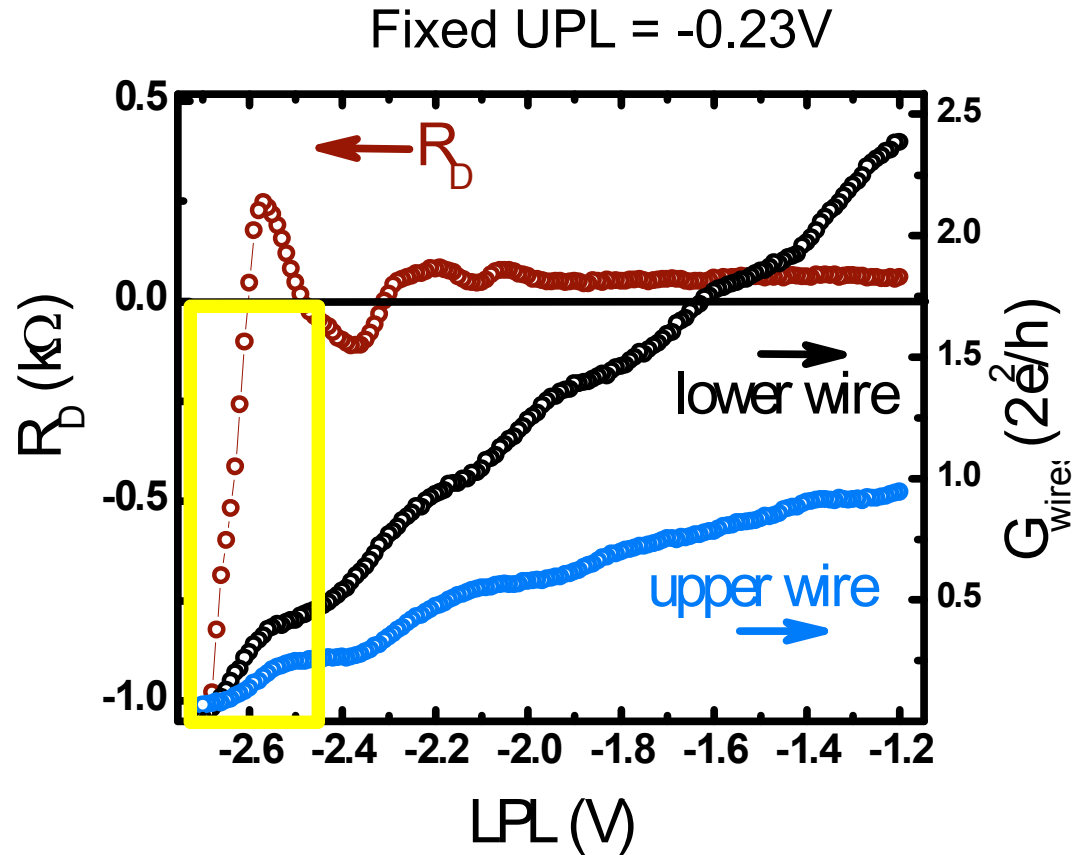
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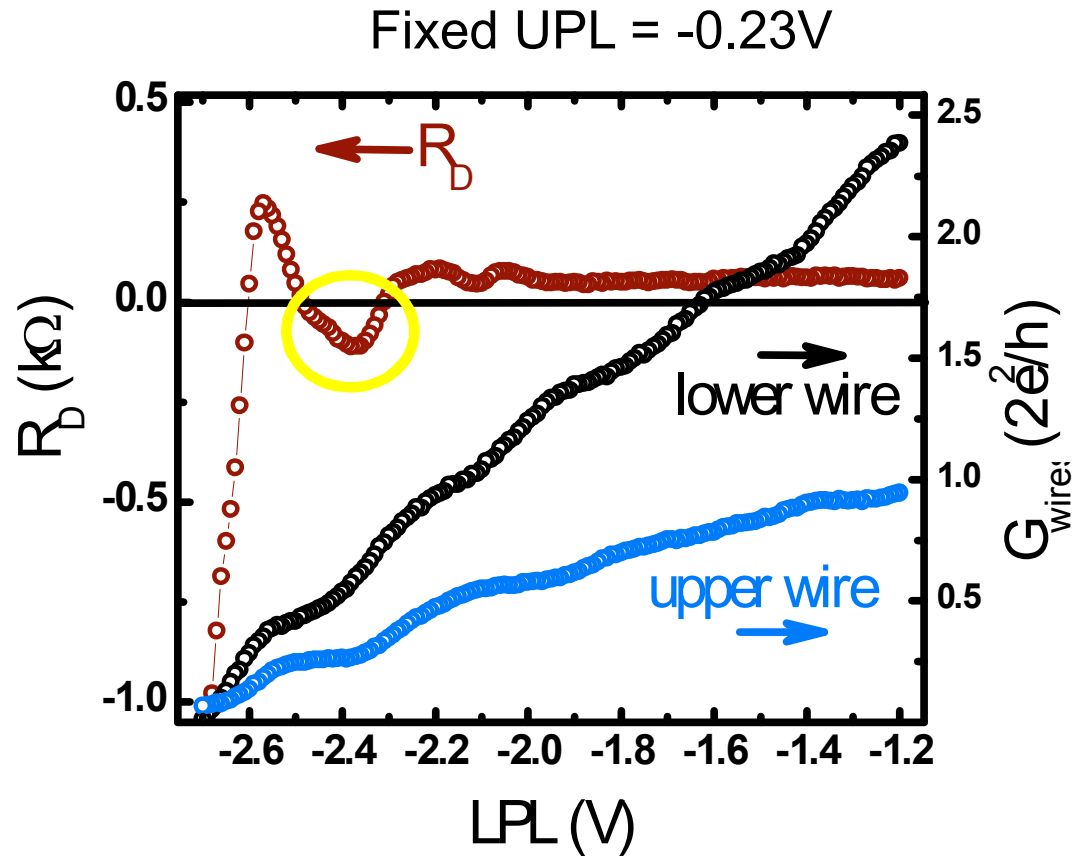


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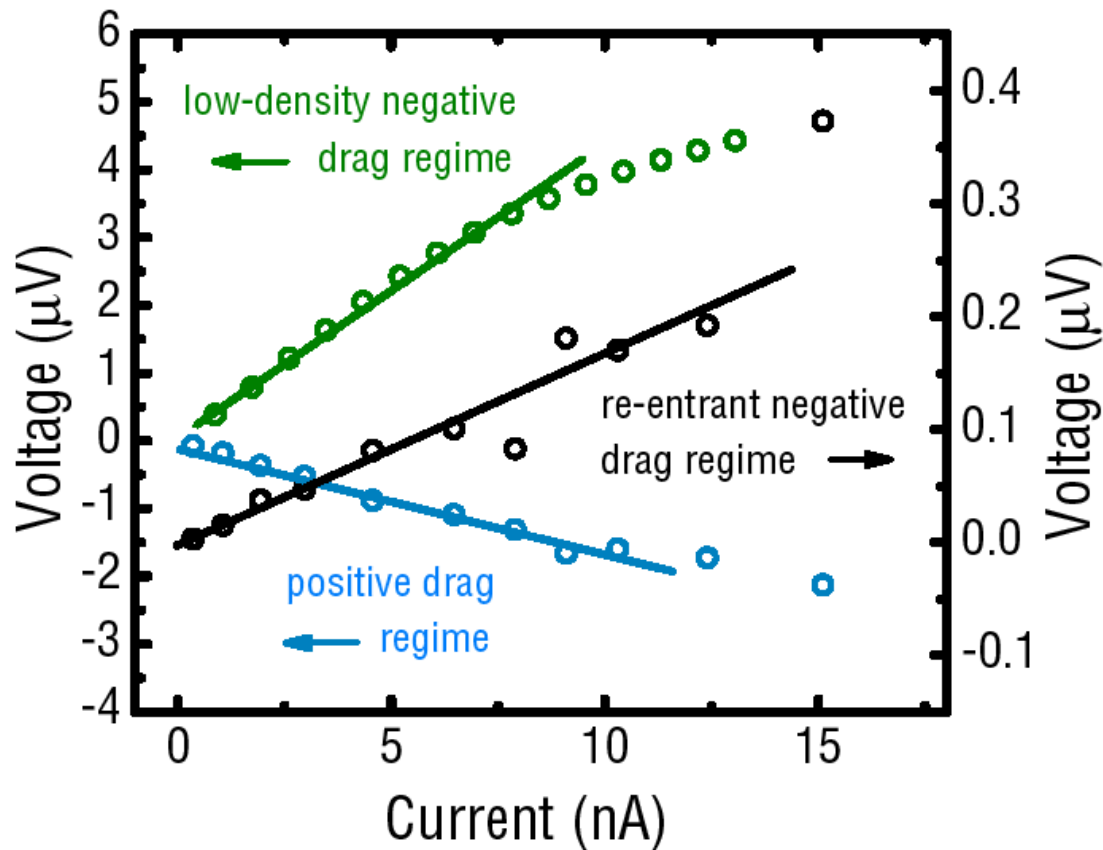
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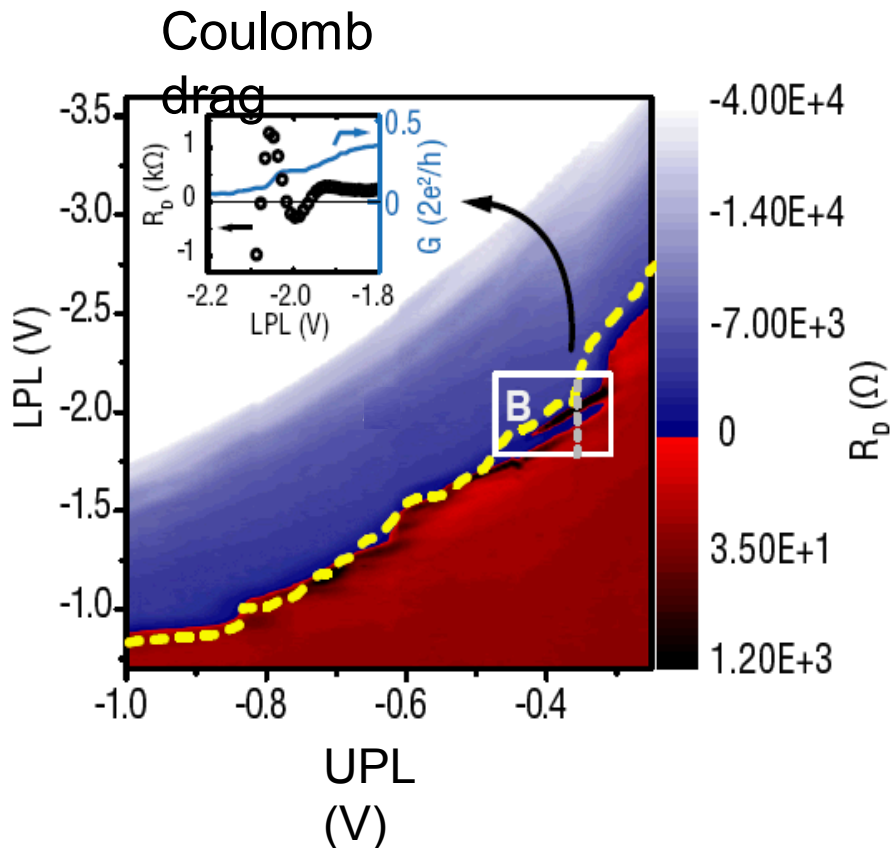
# Consistency test for Coulomb drag



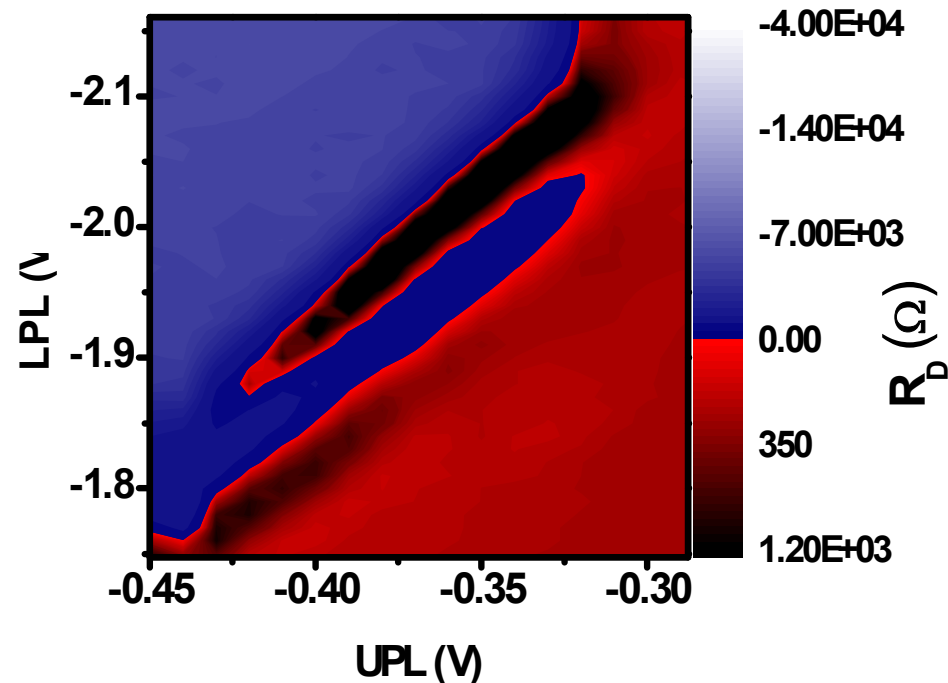
- Linear with drive current
- Drag resistance is independent of frequency
- No DC response is measured in the drag wire while sending an AC drive current



# Mapping of the Coulomb drag



Zoom on re-entrant negative Coulomb drag



- Features in the drag signal can be tracked over large range of gate voltage
- Line up with subband occupancy mapping of the wires



# Interpretation of re-entrant negative drag

- Low-density negative drag : heuristically attributed to Wigner crystallization
  - Re-entrant negative drag occurs at density too high for typical Wigner crystallization
- Possible explanations :
  - Gate-dependent enhancement of electron-hole asymmetry coupled with non-monotonic increase in transmission probability of electrons along wire.<sup>1</sup>
  - Local hole-like dispersion relation in the quantum wires band structure



# Conclusion and future plans

## First vertically coupled quantum wires with :

- Independent control over subbands occupancy
- Independent contacts to each wire

## Coulomb drag measurements

- Study drag with multiple 1D subbands regime
- Reproduce qualitatively other 1D drag experiments
- Observe a new re-entrant negative drag regime at high density

## Future plans

- Measure temperature dependence of Coulomb drag in vertical structures
- Measure Coulomb drag in devices with a smaller interwire

# General Coulomb drag measurements

Measured quantity : transresistance

$$R_D = \frac{-V_{\text{drag}}}{I_{\text{drive}}}$$

